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Modern Methods for Measuring the Functional Characteristics of Surfaces

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Message from the Guest Editors

The aim of this Special Issue is to provide an international forum for the dissemination of scientific information on surface metrology—submission from all fields involving the measurement and characterization of surface topography, including archaeology, art conservation, anthropology, biology, biomedical engineering, chemistry. engineering, food science, forensics, geodetics, geology, material science, mechanical engineering, manufacturing, metrology, nanotechnology, tribology, and others. The Special Issue covers the modelling, design, characterization of surfaces and the relationship between surface properties and their applications. This Special Issue accepts high-quality articles containing original research results and review papers regarding metrology, development, and application of the science technology of measurement, instrumentation and characterisation

Deadline for manuscript submissions:

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Specialsue







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Message from the Editor-in-Chief

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